n re the Application of	Confirmation No. 7016
CHIMURA et al	Examiner: JOHNSON, Connie P.
Serial No.: 10/520,106	Art Unit: 1795
Filed: January 3, 2005	)

For: ACTIVE RAY SENSITIVE RESIN COMPOSITION, ACTIVE ENERGY RAY

SENSITIVE FILM AND METHOD FOR FORMING PATTERN USING THE FILM

## **RESPONSE TO OFFICE ACTION OF JUNE 11, 2008**

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Responsive to the office action of January 24, 2008, please amend the captioned application as follows.